



ADVANCE PROGRAM

2022 DISPLAY WEEK INTERNATIONAL SYMPOSIUM

May 10-13, 2022 (Tuesday – Friday)
San Jose McEnery Convention Center
San Jose, California, US

Session 1: Annual SID Business Meeting

Tuesday, May 10, 2022 / 8:00 – 8:20 am / Room 220A

Session 2: Opening Remarks / Keynote Addresses

Tuesday, May 10, 2022 / 8:20 – 10:20 am / Room 220A

Chair: *Ruiqing (Ray) Ma, Nanosys*

2.1: **Keynote Address 1:** *The New Normal and Displays, Soo-Young Yoon, LG Display Co., Ltd.*

2.2: **Keynote Address 2:** *Displays for AR/VR: Challenges and Trends, Joseph O'Keeffe, Meta*

2.3: **Keynote Address 3:** *Empowering IoT with Displays — the Future and the Pathways, Xiaguang Xu, BOE Technology Group Co., Ltd.*

Session 3: QD-LEDs I (Emissive, Micro-LED, and Quantum-Dot Displays)

Tuesday, May 10, 2022 / 11:10 AM - 12:30 PM / Room 220C

Chair: *Norman Bardsley, Bardsley Consulting*

Co-Chair: *Jonathan Steckel, ST Microelectronics*

- 3.1: **Invited Paper:** *Failure Mechanism of Cadmium-Based Blue Quantum Dot Light-Emitting Diodes by using Electrochemical Impedance Spectroscopy and Stabilization of Core-Shell ZnO Nanoparticles*
Baek Kim, NanoPhotonica, Gainesville, FL US
- 3.2: **Analyzing the Degradation Process of Quantum-Dot LEDs (QLEDs) by Mass Spectrometry**
Hinwai Mo, Fukuoka i3-Center for Organic Photonics and Electronics Research (i3-opera), Fukuoka, Japan
- 3.3: **Distinguished Paper:** *All Inkjet-Printed RGB Cd-Free EL-QD Devices with Top-Emission Structure*
Myoungjin Park, Samsung Display Co., Ltd., Yongin, South Korea
- 3.4: **Highly Efficient Green Top-Emission Light-Emitting Diodes Based on Indium Phosphide Quantum Dot**
Di Zhang, BOE Technology Group Co., Ltd., Beijing, China

Session 4: Oxide TFTs for OLED Displays (Active Matrix Devices)

Tuesday, May 10, 2022 / 11:10 AM - 12:10 PM / Room LL21CD

Chair: *Mike Hack, Universal Display Corporation*

Co-Chair: *Yusin Lin, Applied Materials, Inc.*

- 4.1: **Development of Ultra-Large 95inch 8K 120Hz OLED Display**
Zhongyuan Wu, Hefei BOE Joint Technology Co., Ltd., Hefei, China
- 4.2: **High Performance, Coplanar Polycrystalline InGaO Thin Film Transistor for Large Area, High Resolution AMOLED Display**
Jin Jang, Kyung Hee University, Seoul, South Korea
- 4.3: **Invited Paper: High Mobility Oxide Thin-Film Transistors for AMOLED Displays**
Joon Seok Park, Samsung Display, Inc., Yongin, South Korea

Session 5: Advanced Compensation Techniques (Display Electronics)

Tuesday, May 10, 2022 / 11:10 AM - 12:10 PM / Room LL21EF

Chair: *Taesung Kim, Google LLC*

Co-Chair: *Soo-Yeon Lee, Seoul National University*

- 5.1: **Implementation of Full-Panel Circuit Models for Interference Estimation Between Touch and Display Operation in On-Cell Touch AMOLED**
Seung-Hun Choi, Korea University, Seoul, South Korea
- 5.2: **Tracing-Based Degradation Estimation Method for Stress Profile Algorithm**
Seokha Hong, Samsung Display, Yongin, South Korea
- 5.3: **A Random Access Gate Driver Using a-IGZO TFTs for External Compensation of High-Resolution, High-Frame-Rate AMOLEDs**
Byong-Deok Choi, Hanyang University, Seoul, South Korea

Session 6: AR/MR - LC Optics and Displays (Liquid Crystal Technology)

Tuesday, May 10, 2022 / 11:10 AM - 12:10 PM / Room LL20BC

Chair: *Lu Lu, Facebook Reality Labs*

Co-Chair: *Shin Tson Wu, University Of Central Florida*

- 6.1: **Invited Paper: Tutorial on Diffractive Liquid Crystal Devices for AR/VR Displays**
Shin-Tson Wu, University of Central Florida, Orlando, FL US
- 6.2: **Invited Paper: High-PPI Fast-Switch Display Development for Oculus Quest 2 VR Headsets**
Cheonhong Kim, Meta, Sunnyvale, CA US

Session 7: Under Display Camera Systems (Interactive Displays and Systems / Display Electronics / OLEDs)

Tuesday, May 10, 2022 / 11:10 AM - 12:50 PM / Room LL20A

Chair: *Jongseo Lee, Google*

Co-Chair: *Martin Grunthaner, Apple*

- 7.1: **Invited Paper: UDC Technology for OLED Display**
Junhui Lou, Visionox Technology Inc., Kunsan, China
- 7.2: **High Transmittance Under-Display Camera Structure with COE**
Chuanxiang Xu, BOE, Beijing, China
- 7.3: **OLED Camera-Under Panels with Improved Imaging Quality**
Lei Wang, Wuhan Tianma Microelectronics, Wuhan, China
- 7.4: **Correction Algorithm for Under-Display Camera Area on AMOLED Display**
Shang-Yu Su, Novatek Microelectronics Corporation, Hsinchu, Taiwan Roc
- 7.5: **Synthetic Dataset for Improving UDC Video Restoration Network Performance**
Hyunjoo Hwang, Samsung Display, Youngin, South Korea

Session 8: QD-LEDs II (Emissive, Micro-LED, and Quantum-Dot Displays)

Tuesday, May 10, 2022 / 2:00 PM - 3:40 PM / Room 220C

Chair: *Jean-Jacques Drolet, Osram Opto Semiconductors*

Co-Chair: *Jonathan Steckel, ST Microelectronics*

- 8.1: **Invited Paper: Development of High Efficiency QLED Technology for Display Applications**
Yanzhao Li, BOE Technology Group Co., Ltd., Beijing, China
- 8.2: **Invited Paper: Development of Active-Matrix nanoLED Display Using Heavy Metal Free QDs Patterned by Photolithography Process**
Yohei Nakanishi, Sharp Display Technology Corporation, Nara, Japan
- 8.3: **Development of Highly Efficient RGB Cadmium-Free Quantum Dot Light-Emitting Diodes**
Tatsuya Ryowa, Sharp Corporation, Tenri, Japan
- 8.4: **Degradation Analysis of InP-Quantum Dot Light-Emitting Diodes**
Raju Lampande, Kyung Hee University, Seoul, South Korea
- 8.5: **Inkjet-Printed Quantum Dot/Organic Semiconductor Nanohybrids for Efficient InP-Based Quantum Dot Light-Emitting Diodes**
Yohan Kim, Fraunhofer Institute for Applied Polymer Research (IAP), Potsdam, Germany

Session 9: High Performance TFT Sensors (Active Matrix Devices / Emerging Technologies and Applications)

Tuesday, May 10, 2022 / 2:00 PM - 3:20 PM / Room LL21CD

Chair: *Yusin Lin, Applied Materials, Inc.*

Co-Chair: *Vincent Gu, Apple, Inc.*

- 9.1: **Evaluation of X-Ray Resistance of Submicron-Size c-Axis Aligned Crystalline Oxide Semiconductor**
Kazuki Tsuda, Semiconductor Energy Laboratory Co., Ltd., Atsugi, Japan
- 9.2: **Oxide TFT Behavior Under X-ray Irradiation in DXD Backplane**
YounGyoung Chang, LG Display, Seoul, South Korea
- 9.3: **Widening the Wavelength Absorption Range of Indium Gallium Zinc Oxide Phototransistors through the Capping Layer**
Hyun Jae Kim, Yonsei University, Seoul, South Korea
- 9.4: **Fabrication of the Indirect X-Ray Detector Using Organic Photodiode**
Kyung-Tae Kang, Korea Institute of Technology (KITECH), Ansan, South Korea

Session 10: High-PPI OLED and Micro-LED Displays (Display Electronics)

Tuesday, May 10, 2022 / 2:00 PM - 3:00 PM / Room LL21EF

Chair: *Carlin Vieri, Google*

Co-Chair: *Hyoungsik Nam, Kyung Hee University*

- 10.1: **Layout of 1.50-inch, 3207-ppi OLED Display with OSLSI/SILSI Structure Capable of Division Driving Fabricated through VLSI Process with Side-by-Side Patterning by Photolithography**
Toshihio Saito, Semiconductor Energy Laboratory Co. Ltd., Atsugi, Japan
- 10.2: **Dual-Driver Pixel Circuit and Associated Drivers for Low-Power OLEDs Microdisplays**
Sheida Gohardehi, University of Waterloo, Waterloo, ON Canada
- 10.3: **A Novel PAM-PWM Hybrid Driving Method for Micro-LED Displays**
Yingteng Zhai, Tianma Microelectronics Co., Ltd., Shanghai, China

Session 11: AR/MR - High Speed LC (Liquid Crystal Technology)

Tuesday, May 10, 2022 / 2:00 PM - 3:00 PM / Room LL20BC

Chair: *Takahiro Ishinabe, Tohoku University*

Co-Chair: *Hoi-Sing Kwok, Hong Kong University of Science & Technology*

- 11.1: **100 Microseconds Response In-Plane Only Retardation Switching by Applied Voltage Polarity Dependent Smectic Liquid Crystals**
Akihiro Mochizuki, i-CORE Technology, LLC, Louisville, CO US
- 11.2: **High Brightness and Ultra-high PPI Field-Sequential-Color (FSC) Display based on Deformed Helix Ferroelectric Liquid Crystal for VR/AR**
Zhibo Sun, Hong Kong University of Science and Technology, Hong Kong, Hong Kong
- 11.3: **Invited Paper: New Materials for Film Optics and Game Changing Head Mount Devices**
Owain Parri, Merck Performance Materials Ltd., Southampton, United Kingdom

Session 12: Integrated Optical Sensing Displays (Interactive Displays and Systems)

Tuesday, May 10, 2022 / 2:00 PM - 3:20 PM / Room LL20A

Chair: *Jeff Han, Consultant*

Co-Chair: *Steven Bathiche, Microsoft*

- 12.1: **Invited Paper: Through-OLED Ambient Color Sensing**
Kenneth Vampola, Apple, Cupertino, CA US
- 12.2: **High Accuracy In-Cell Integrated Ambient Light and Color Temperature Sensor LCD**
Hui Guang Liu, TCL China Star Optoelectronics Technology Co., Ltd., Wuhan, China

- 12.3: **Investigation of Fingerprint on Display Technology for FLI Display**
Chuanxiang Xu, BOE, Beijing, China
- 12.4: **Tomography May Enable a Wavelength-Thin Camera**
Adrian Travis, Travoptics, Paris, France

Session 13: QD-LEDs III (Emissive, Micro-LED, and Quantum-Dot Displays)

Tuesday, May 10, 2022 / 3:40 PM - 5:20 PM / Room 220C

Chair: *Seth Coe-Sullivan, NS Nanotech*

Co-Chair: *Jonathan Steckel, ST Microelectronics*

- 13.1: **Invited Paper: Optimizations for the Commercialization of Ink-Jet Printing Quantum Dots Light Emitting Diodes Based Display**
Wenyong Liu, TCL, Shenzhen, China
- 13.2: **Modification of ZnMgO NPs for Improving Device Performance of All-Inkjet-Printed Quantum Dot Light-Emitting Diodes**
Jaekook Ha, Samsung Display Co., Ltd., Yongin, South Korea
- 13.3: **Invited Paper: Large-Area Solution-Processed NIR and SWIR Sources Based on Colloidal Quantum Dots**
Ted Sargent, University of Toronto, Toronto, Canada
- 13.4: **Invited Paper: Progress in SWIR Colloidal Quantum Dot Light Emitters: LEDs, Downconverters and Lasers**
Gerasimos Konstantatos, ICFO, Castelldefels, Spain
- 13.5: **Quantum Dot-in-Perovskite Near Infrared Light-Emitting Diodes**
Abd. Rashid Yusoff, Pohang University of Science and Technology (POSTECH), Pohang, South Korea

Session 14: Advanced IGZO/LTPS Devices (Active Matrix Devices)

Tuesday, May 10, 2022 / 3:40 PM - 5:00 PM / Room LL21CD

Chair: *Kenichi Takatori, Huawei Technologies Japan K.K.*

Co-Chair: *James Chang, Apple, Inc.*

- 14.1: **Enhanced Reliability Characterization of Pixel Circuit Featuring IGZO Device for Competitive Display Performance**
Taeyoung Khim, Samsung OLED Business, Yongin, South Korea
- 14.2: **Enhanced Electrical Characteristics of Low-Temperature Processed In-Ga-Zn-O Thin-Film Transistors with Oxygen Scavenging Layer**
Hyun Jae Kim, Yonsei University, Seoul, South Korea
- 14.3: **Extremely Short-Channel LTPS TFT Technologies for High-Performance Low-Power and Reliable AMOLED Displays**
Keunwoo Kim, Samsung Display, Youngin, South Korea
- 14.4: **Enhanced Low Temperature Polycrystalline Silicon Thin Film Transistor Device Structure by Doping at Channel Edge**
Seunghyun Jang, Samsung Display Company, Yongin, South Korea

Session 15: Ultra Low Power Driving , High-Speed I/F and IC Architecture (Display Electronics)

Tuesday, May 10, 2022 / 3:40 PM - 4:40 PM / Room LL21EF

Chair: *Dr. Bong-Hyun You, Samsung Display Co.*

Co-Chair: *Dr. Juhn Yoo, LG Display*

- 15.1: **A Novel Multi-Frequency Driving of OLED for Low Power Consumption**
Sangan Kwon, Samsung Display, Yongin, South Korea
- 15.2: **A 6.0Gbps Clock Embedded Interface for Advanced Mobile Display**
Dongwon Park, Samsung Display, Yongin, South Korea
- 15.3: **Cost-Effective Display Driver IC Architecture for First Frame Drop Compensation with Shared Memory Interface**
Jin-Yong Park, Samsung Electronics Co., Gyeonggi, South Korea

Session 16: AR/MR - LC Lenses and Components (Liquid Crystal Technology)

Tuesday, May 10, 2022 / 3:40 PM - 4:40 PM / Room LL20BC

Chair: *Linghui Rao, Meta (Facebook)*

Co-Chair: *Michael Wittek, Merck KGaA*

- 16.1: **Optical Performance Characterization of 5 cm Aperture Size Continuous Focus Tunable Liquid Crystal Lens for Resolving Accommodation-Convergence Mismatch Conflict of AR/VR/3D HMDs**
Amit Bhowmick, Kent State University, Kent, OH US
- 16.2: **Distinguished Paper: Thin and Low-Reflection Metal Black Matrix for High PPI LCD**
Keisuke Yoshida, Sharp Display Technology Corporation, Tenri, Japan
- 16.3: **Compact Tunable Alvarez Lens Based on Pancharatnam-Berry Optical Elements**
Yan Li, Shanghai Jiao Tong University, Shanghai, China

Session 17: Capacitive Touch (Interactive Displays and Systems)

Tuesday, May 10, 2022 / 3:40 PM - 5:00 PM / Room LL20A

Chair: *Dr. John Zhong, Apple, Inc.*

Co-Chair: *Patrick Worfolk, Synaptics*

- 17.1: **Self-Capacitive Touch Sensor Design for OLED On-Cell Touch**
Yu-Ying Tang, Novatek Microelectronic Corp., Hsinchu, Taiwan Roc
- 17.2: **Integrated Self-Capacitance Touch Panel for Flexible OLED Display**
Feng Lu, Shanghai Tianma Micro-electronics Co., Ltd., Shanghai, China
- 17.3: **A Novel Solution to Proximity Detection with On-Cell Capacitive Touch Sensor**
Soongyu Lee, Samsung Display, Yongin, South Korea
- 17.4: **An Avionics Touchscreen Display for Safety Critical Applications**
Philippe Coni, Thales Avionics SAS, Merignac, France

Session 18: Human Vision and Evaluation Methods for AR/VR/MR (Hyper-Realistic Displays (AR/VR/MR) / Applied Vision / Display Measurement)

Wednesday, May 11, 2022 / 9:00 AM - 10:00 AM / Room 220B

Chair: *Jisoo Hong, Korea Electronics Technology Institute*

Co-Chair: *Soon-Gi Park, LetinAR*

- 18.1: **Invited Paper:** **Modeling and Optimizing Human-in-the-Loop Visual Perception Using Immersive Displays: A Review**
Qi Sun, New York University, Brooklyn, NY US
- 18.2: **Assessment of Image Quality in Augmented Reality Displays Using a Computational Model of Target Detectability**
Chumin Zhao, U.S. Food and Drug Administration, Silver Spring, MD US
- 18.3: **3D Image Quality Evaluation Method Based on Image Comparison Metrics**
Young-sang Ha, Samsung Display, Yongin, South Korea

Session 19: QD Color Conversion I (Emissive, Micro-LED, and Quantum-Dot Displays)

Wednesday, May 11, 2022 / 9:00 AM - 10:20 AM / Room 220C

Chair: *John Van Derlofske, 3M*

Co-Chair: *Michele Ricks, EMD Electronics*

- 19.1: **Invited Paper:** **Quantum Dot Display**
Shinae Jun, Samsung Advanced Institute of Technology, Suwon, South Korea
- 19.2: **Design Heuristics of Color Conversion Films in Micro LED Displays**
Khaled Ahmed, Intel Corporation, San Jose, CA US
- 19.3: **The Crucial Effect of Aspect Ratio of Quantum Dot Color-Conversion Pixels on the Performance of High-Resolution Full-Color MicroLED Microdisplay**
Ray-Kuang Chiang, Taiwan Nanocrystals Corp. Ltd., Tainan City, Taiwan Roc
- 19.4: **Triboelectric Discharging Problems in QD-OLED Manufacturing and Solutions Using Electromagnetic Analysis**
Hyun Sung Park, Samsung Display, Youngin, South Korea

Session 20: Advanced Active Matrix Backplanes (Active Matrix Devices)

Wednesday, May 11, 2022 / 9:00 AM - 10:20 AM / Room LL21CD

Chair: *Hyun Jae Kim, Yonsei University*

Co-Chair: *Sang-Hee Park, KAIST*

- 20.1: **Distinguished Paper:** **Advanced Hybrid Process with Back Contact IGZO-TFT**
Masatomo Honjo, Sharp Display Technology Corporation, Nara, Japan
- 20.2: **Integration of Through Glass Via Interconnects within Thin Film Transistor Active Matrix Backplanes**
Rajesh Va, Corning Research & Development Corporation, Corning, NY US
- 20.3: **Invited Paper:** **BEOL-Compatible Ferroelectric Field-Effect Transistors with Atomic Layer Deposition of Oxide Semiconductor Channel Toward Monolithic 3D Integration**
Mengwei Si, Shanghai Jiao Tong, 800 Dongchuan Rd, China
- 20.4: **High-Performance p-Channel Tellurium Thin-Film Transistor Applications Fabricated at a Low Temperature of 150 °C**
Jae Kyeong Jeong, Hanyang University, Seoul, South Korea

Session 21: OLED Optics (OLEDs)

Wednesday, May 11, 2022 / 9:00 AM - 10:20 AM / Room LL21EF

Chair: *CC Lee, Visionox*

Co-Chair: *Yifan Zhang, Apple, Inc.*

- 21.1: **Invited Paper:** **Polarized Emission Thin-Film Light Emitting Diodes**
Franky So, North Carolina State University, Raleigh, NC US
- 21.2: **Invited Paper:** **Improve OLED Light Outcoupling Efficiency by Eliminating Waveguide Mode Using Ultrathin Metal Electrode**
L. Jay Guo, University of Michigan, Ann Arbor, MI US
- 21.3: **Effect of Ag Adhesion Layer on Plasmon Outcoupling Efficiency**
Nicholas Thompson, Universal Display Corporation, Ewing, NJ US
- 21.4: **Implications of Spatial Coherence on Minimizing Diffractive Reflection Artifacts in OLED Displays**
S. Matthew Menke, 3M, St. Paul, MN US

Session 22: Emerging Liquid Crystal Technologies (Liquid Crystal Technology)

Wednesday, May 11, 2022 / 9:00 AM - 10:20 AM / Room LL20BC

Chair: *Xiao-Yang Huang, Ebulent Technologies Corp*

Co-Chair: *Gang Xu, Huawei*

- 22.1: **Invited Paper:** **Electrically Switchable Privacy Technology Suitable for Laptop PC**
Dong Jin Lee, LG Display, Paju, South Korea
- 22.2: **Field Sequential Color See-Through Panel Development**
Shinichi Terashita, Sharp Display Technology Corporation, Nara, Japan
- 22.3: **A New Near Infrared Polarizer with High Visible Transparency and its Sensor Applications**
Mayumi Nojiri, FUJIFILM Corporation, Minamiashigara, Japan
- 22.4: **Invited Paper:** **Display on Demand**
Ya-Ling Hsu, AU Optronics Corporation, Hsinchu, Taiwan Roc

Session 23: Advanced Display Characterization Methods (Display Measurement)

Wednesday, May 11, 2022 / 9:00 AM - 10:20 AM / Room LL20A

Chair: *Stephen Atwood, Consultant*

Co-Chair: *Thomas Fiske, Microsoft*

- 23.1: **Invited Paper:** **Visualization of Color Gamut Coverage—Gamut Ring Intersection**
Kenichiro Masaoka, NHK Science & Technology Research Laboratories, Setagaya, Japan
- 23.2: **Characterization of Directional Chromaticity of Cylindrically Curved OLED**

- K Kälantär, Global Optical Solutions, Hachioji, Japan*
- 23.3: **Distinguished Paper:** Utilizing Advanced Spatio-Temporal Backgrounds with Dynamic Test Signals for HDR Display Metrology
Timo Kunkel, Dolby Laboratories, Inc., San Francisco, CA US
- 23.4: **Quick Detection and Evaluation of Irregular Response Time Behavior for High Frame Rate Displays Through Noticeable Artifacts**
Isao Kawahara, FairSpec & Co. LLC, Toyonaka, Japan

Session 24: Emerging Applications of Display Technology (*Emerging Technologies and Applications*)

Wednesday, May 11, 2022 / 9:00 AM - 10:20 AM / Room LL20D

Chair: *Adi Abileah, Adi - Displays Consulting LLC*

Co-Chair: *Susan Jones, Nulumina Corp.*

- 24.1: **Can Light Microscopes Be Really Chip-Sized?**
Angel Dieguez, University of Barcelona, Barcelona, Spain
- 24.2: **Development of Methods to Reduce Blue Light Hazard from Displays**
Derek Harris, Eyesafe Inc., St. Paul, MN US
- 24.3: **Distinguished Paper:** Towards a Solid-State LIDAR Using Holographic Illumination and a SPAD-Based Time-Of-Flight Image Sensor
Konstantinos Bantounos, University of Edinburgh, Edinburgh, United Kingdom
- 24.4: **High Precision Beam Angle Expander Based on Polymeric Liquid Crystal Polarization Lenses for LiDAR Applications**
Yannanqi Li, University of Central Florida, Orlando, FL US

Session 25: Innovations in Microdisplays for AR/VR/MR (*Hyper-Realistic Displays (AR/VR/MR) / Display Manufacturing*)

Wednesday, May 11, 2022 / 10:40 AM - 12:00 PM / Room 220B

Chair: *Ion Bita, Google LLC*

Co-Chair: *Yunhee Kim, Samsung Electronics*

- 25.1: **Invited Paper:** OLED Microdisplays for AR/VR Applications: Technical Approaches Toward Realization of over 10,000 Nits Full Color Panels
Jang Jo, LG Display, Seoul, South Korea
- 25.2: **Invited Paper:** Ultra-High-Resolution nanoLED Panel for AR/VR by UV Patterning Technology
Kazuya Tsujino, Sharp Display Technology Corporation, Tenri, Nara, Japan
- 25.3: **RGB Direct Patterning for 3,000ppi OLED Micro-Display**
Chiwoo Kim, APS Research, Hwaseong, South Korea
- 25.4: **Invited Paper:** Contact Lens Embedded MicroLED Micro-Displays
Paul Martin, Mojo Vision, Saratoga, CA US

Session 26: QD Color Conversion II (*Emissive, Micro-LED, and Quantum-Dot Displays*)

Wednesday, May 11, 2022 / 10:40 AM - 12:00 PM / Room 220C

Chair: *Juanita Kurtin, OSRAM Opto Semiconductors*

Co-Chair: *John Van Derlofske, 3M*

- 26.1: **Invited Paper:** Challenges in QD OLED Display Technology
Ingo Koehler, Merck KGaA, Darmstadt, Germany
- 26.2: **How Perovskite Quantum Dots are Supporting the Rise of Mini-LED Based LCD Displays**
Norman Luechinger, Avantama AG, Stafa, Switzerland
- 26.3: **Optical Modeling of Quantum Dot-OLED (QD-OLED) Color Conversion**
Peter Palomaki, Palomaki Consulting, LLC, Billerica, MA US
- 26.4: **Perovskite Inks and Photoresists for In-Pixel Color Conversion**
Bernard Wenger, Helio Display Materials Ltd., Oxford, United Kingdom

Session 27: High Resolution Display Technology I (*Active Matrix Devices*)

Wednesday, May 11, 2022 / 10:40 AM - 11:40 AM / Room LL21CD

Chair: *Dr. Kalluri Sarma, Display Technology Consulting*

Co-Chair: *Chen Xi, BOE Technology Group Co., Ltd.*

- 27.1: **Fabrication Method for Miniaturized CAAC-OS FET for High-Definition AR/VR Displays**
Ryota Hodo, Semiconductor Energy Laboratory Co. Ltd., Atsugi, Japan
- 27.2: **Novel LTPS TFT Backplane Structure on Glass for 1443ppi 4.3" AMOLED VR Displays**
Kummi Oh, LG Display, Paju, South Korea
- 27.3: **Invited Paper:** High Performance Sub-50nm Channel Length 3-D Monolithically Stackable Vertical IGZO TFTs for Active Matrix Application
Di Geng, Chinese Academy of Sciences, Beijing, China

Session 28: OLED Physics and Simulations (*OLEDs*)

Wednesday, May 11, 2022 / 10:40 AM - 12:00 PM / Room LL21EF

Chair: *Denis Kondakov, DuPont*

Co-Chair: *Nicholas Thompson, Universal Display Corporation*

- 28.1: **Invited Paper:** Bottom-Up OLED Development By Virtual Design: Systematic Elimination of Performance Bottlenecks Using a Microscopic Simulation Approach
Tobias Neumann, Nanomatch GmbH, Karlsruhe, Germany
- 28.2: **Invited Paper:** Accelerating OLED R&D with Digital Twins
Arthur Vauzelle, Simbeyond B.V., Eindhoven, Netherlands
- 28.3: **Invited Paper:** Enhanced Current Efficiency and Accumulation Charge in Model OLEDs by Light Irradiation During Deposition of Polar Molecule
Yuya Tanaka, Chiba University, Chiba, Japan
- 28.4: **Invited Paper:** Effects of Guest Clustering Morphology in Phosphorescent OLEDs
Jeremy Zimmerman, Colorado School of Mines, GOLDEN, CO US

Session 29: Green, Low Power/Stretchable /LCDs (*Liquid Crystal Technology*)

Wednesday, May 11, 2022 / 10:40 AM - 12:00 PM / Room LL20BC

Chair: *Dr. Philip Chen, National Chiao Tung University*

Co-Chair: *Matthew Sousa, 3M*

- 29.1: **Invited Paper:** Strategies to Improve Carbon Footprint of TFT Liquid Crystal Display
Deeder Aurongzeb, Dell Company, Austin, TX US
- 29.2: **Invited Paper:** An Ultra-Low Power FFS LCD Using Zero-Anchoring interface
Hiroaki Asagi, Sharp Display Technology Corporation, Nara, Japan
- 29.3: **Invited Paper:** Ultra-Thin Stretchable LCD Using Deformable Polarizer
Ryo Kawamura, Nitto Denko Corporation, Osaka, Japan
- 29.4: **Novel High Impedance Driving of Zenithal Bistable LCDs**
Guy Bryan-Brown, New Vision Display, Malvern, United Kingdom

Session 30: Spatial and Temporal Display Metrology (Display Measurement)

Wednesday, May 11, 2022 / 10:40 AM - 12:00 PM / Room LL20A

Chair: *Stephen Atwood, Consultant*

Co-Chair: *Frank Rochow, Adviser*

- 30.1: **High-Precision High-Resolution Measurements within Moiré**
Ingo Rotscholl, TechnoTeam Bildverarbeitung GmbH, Ilmenau, Germany
- 30.2: **Visualization and Rating of Motion Artifacts by Analyzing Asymmetric Response Time Behavior**
Isao Kawahara, FairSpec & Co. LLC, Toyonaka, Japan
- 30.3: **A Moving Camera and Synthetic Calibration Target Solution for Non-Planar Scene Estimation and Projector Calibration**
Katherine Arnold, University of Waterloo, Waterloo, ON Canada
- 30.4: **Requirements for Reliable Display Sparkle Contrast Measurement: Analysis in Spatial Frequency Domain**
Masanobu Isshiki, AGC Inc., Yokohama, Japan

Session 31: Novel Display Technology Approaches (Emerging Technologies and Applications)

Wednesday, May 11, 2022 / 10:40 AM - 11:40 AM / Room LL20D

Chair: *Mr Timothy Large, Microsoft Corp*

Co-Chair: *Abhishek Srivastava, Hong Kong University of Science & Technology*

- 31.1: **Numerical Approach for Sound Quality Prediction of the Large-Sized OLED Panel Speaker**
Hyundo Shin, Samsung Display Co., Ltd., Yongin-si, South Korea
- 31.2: **Fermi Level Prediction of Solution-Processed Ultra-wide Band gap a-Ga2Ox via Supervised Machine Learning Models**
Juan Bermundo, Nara Institute of Science and Technology, Ikoma, Japan
- 31.3: **Multi-Primary Wide Gamut Color Systems**
Gary Feather, 6p Color, Portland, OR US

Session 32: High Resolution Display Technology II (Active Matrix Devices)

Wednesday, May 11, 2022 / 3:30 PM - 4:50 PM / Room LL21CD

Chair: *Norbert Fruehauf, University of Stuttgart*

Co-Chair: *Man Wong, Hong Kong University of Science & Technology*

- 32.1: **Oxide Semiconductor Field-Effect Transistor for High-Resolution Displays Capable of Deep Black Display**
Yuuka Okazaki, Semiconductor Energy Laboratory Co., Ltd., Atsugi, Japan
- 32.2: **An Optical Compensation Scheme for High PPI AMOLED Display**
Ying Han, Hefei BOE Joint Technology Co. Ltd., Hefei, China
- 32.3: **1.5-inch, 3207-ppi Side-by-Side OLED Display Capable of 32-Division Driving with OSLSI/SiLSI Structure Fabricated by Photolithography**
Munehiro Kozuma, Semiconductor Energy Laboratory Co. Ltd., Atsugi, Japan
- 32.4: **Metal Oxide Thin-Film Transistors with 0.1 μ m Channel Length Formed by Self-Aligned Nanogap Patterning**
Sung Haeng Cho, Electronics and Telecommunications Research Institute, Daejeon, South Korea

Session 33: Printed OLED (OLEDs)

Wednesday, May 11, 2022 / 3:30 PM - 4:50 PM / Room LL21EF

Chair: *Sven Zimmermann, Novaled GmbH*

Co-Chair: *Denis Kondakov, DuPont*

- 33.1: **Invited Paper:** All-Inkjet-Printed AMOLED Display with Improved Efficiency and Lifetime
Sehun Kim, Samsung Display Co., Ltd., Yongin, South Korea
- 33.2: **Invited Paper:** Flexible OLED Displays with Inkjet Printing Technology
Weiran Cao, Shenzhen China Star Optoelectronics Semiconductor Display Technology Co., Ltd., Shenzhen, China
- 33.3: **Invited Paper:** Research and Applications of Inkjet Printing for OLED Mass Production
Gerry Chen, Kateeva, Inc., Newark, CA US

Session 34: High Dynamic Range LCDs (Liquid Crystal Technology)

Wednesday, May 11, 2022 / 3:30 PM - 5:30 PM / Room LL20BC

Chair: *Jenn Jia Su, AU Optronics Corporation*

Co-Chair: *Koichi Miyachi, JSR Corporation*

- 34.1: **Novel Liquid Crystal Display Mode SUVA4&SUVA5 with Double Photo Alignment Technology for High Definition Display**
Fan Li, BOE Technology Group Co., Ltd., Chengdu, China
- 34.2: **Invited Paper:** Analysis of Temperature Effect of RGB Mini/Micro LED Chips
Yuanhao Sun, BOE MLED Technology Co., Ltd., Beijing, China
- 34.3: **High Contrast Research of 4K ADS TV Technology**
Hongling Hu, Hefei BOE Display Technology Co., Ltd., Hefei, China
- 34.4: **Invited Paper:** UBplus/UB-FFS – Premium Performance for Liquid Crystal TV and IT Displays

- Lawrence Huang, Merck Display Materials Co., Ltd., Shanghai, China
- 34.5: **Invited Paper: C-PS-VA – Innovative LC materials Enabling Super High Transmittance for High Resolution Displays**
Susan Chuang, Merck Performance Materials Ltd., Taoyuan, Taiwan Roc
- 34.6: **Invited Paper: High Image Quality of 8K TV LCDs with Negative LC**
Dong-Chuan Chen, Beijing BOE Display Technology Co., Ltd., Beijing, China

Session 35: Halo Measurements (*Display Measurement / Automotive/Vehicular Displays and HMI Technologies*)

Wednesday, May 11, 2022 / 3:30 PM - 4:50 PM / Room LL20A

Chair: Frank Rochow, Adviser

Co-Chair: Thomas Fiske, Microsoft

- 35.1: **Halo Mura of OLED and FALD LCD: Measurements & Perception for (Automotive) Displays**
Karlheinz Blankenbach, Pforzheim University Display Lab, Pforzheim, Germany
- 35.2: **Proposal for Improved Calculation Method for the Halo Effect in Digital Displays Based on Human Brightness Perception**
Han Byul Lim, Samsung Display, Yongin, South Korea
- 35.3: **The Measurement Method of Halo: Halo Length, Angular Halo**
Hyunah Suh, Samsung Display, Yongin, South Korea
- 35.4: **Systematic Comparisons on Display Performances Including Halo Effect**
Zhiyong Yang, University of Central Florida, Orlando, FL US

Session 36: Novel Processes & MicroOptics (*Emerging Technologies and Applications*)

Wednesday, May 11, 2022 / 3:30 PM - 4:50 PM / Room LL20D

Chair: Fang-Cheng Lin, Apple, Inc.

Co-Chair: Jim Zhuang, Meta

- 36.1: **Invited Paper: Liquid Crystal Lasers: Recent Advances and Future Opportunities**
Philip Hands, School of Engineering, University of Edinburgh, Edinburgh, United Kingdom
- 36.2: **Optimizing Brightness with Micro Lens Array Gain Enhancing Films for Edge-Lit Back Light Units**
Bing Shen, BrightView Technologies, Durham, NC US
- 36.3: **Novel Silicone Hotmelt Adhesive for Display Assembly Applications**
Ryosuke Yamazaki, Dow Toray Co., Ltd., Ichihara, Japan
- 36.4: **Precision Micro-Optics on Display Technical Glass for Innovative Display Designs**
Casey Kang, Corning Incorporated, Corning, NY US

Session 37: Holographic and Autostereoscopic 3D Displays (*Hyper-Realistic Displays (AR/VR/MR) / Display Systems*)

Thursday, May 12, 2022 / 9:00 AM - 10:40 AM / Room 220B

Chair: Yifan (Evan) Peng, Stanford University

Co-Chair: Zong Qin, Sun Yat-Sen University

- 37.1: **Invited Paper: Advances in Neural Holographic Displays for Virtual and Augmented Reality**
Manu Gopakumar, Stanford University, Stanford, CA US
- 37.2: **Invited Paper: Enabling Augmented Reality Near-eye and Head-Up Displays with Neural Holography**
Suyeon Choi, Stanford University, Stanford, CA US
- 37.3: **Method of Color Amplitude-Only Hologram Generation for Speckle Noise Suppression**
Qiong-Hua Wang, Beihang University, Beijing, China
- 37.4: **Depth-Enhanced 2D/3D Switchable Display Based on Integral Imaging**
Qiang Li, Sichuan University, Chengdu, China
- 37.5: **Invited Paper: Flat Panel Holographic Display**
Yunhee Kim, Samsung Electronics Co., Ltd., Suwon, South Korea

Session 38: Micro-LEDs I (*Emissive, Micro-LED, and Quantum-Dot Displays*)

Thursday, May 12, 2022 / 9:00 AM - 10:20 AM / Room 220C

Chair: Chris Bower, X Display Company

Co-Chair: Jonathan Steckel, ST Microelectronics

- 38.1: **GaN Nanowire LED Technology: Moving to Products.**
Xavier Hugon, Aledia, Echirrolles, France
- 38.2: **Latest Breakthroughs in 200 and 300 mm epi Technology to Unlock the Micro LED Revolution for the Metaverse and Beyond**
Atsushi Nishikawa, ALLOS Semiconductors GmbH, Dresden, Germany
- 38.3: **Invited Paper: MicroLED Device Technology for Low Power Wearable Displays**
Oleg Sheekin, Lumileds, San Jose, CA US
- 38.4: **Invited Paper: Inline Screening Known Good Die Mapping for MicroLED**
John Robinson, KLA Corporation, Milpitas, CA US

Session 39: E-Paper and Transparent Display Measurements (*Outdoor Displays / Display Measurement*)

Thursday, May 12, 2022 / 9:00 AM - 10:20 AM / Room LL21CD

Chair: Stephen Atwood, Consultant

Co-Chair: Karlheinz Blankenbach, Pforzheim University

- 39.1: **Distinguished Paper: Gamut Rings of Reflective ePaper Displays with Combined Frontlight and Ambient Illumination**
Dirk Hertel, E Ink Corp., Billerica, MA US
- 39.2: **Evaluating the Components of Reflected Glare in Displays**
John Penczek, University of Colorado, Boulder, CO US
- 39.3: **Fluorescence Enhanced Optical Resonator Constituted of Quantum Dots and Thin Film Resonant Cavity for High-Efficiency Reflective Color Filter**
Qian Wu, BOE Technology Group Co., Ltd., Beijing, China
- 39.4: **High Performance Micro-LED Transparent Display**
Liqun Chen, Tianma Microelectronics Co., Ltd., Shanghai, China

Session 40: OLED Devices I (OLEDs)

Thursday, May 12, 2022 / 9:00 AM - 10:20 AM / Room LL21EF

Chair: Yasunori Kijima, Huawei Technologies Japan K.K.

Co-Chair: Larry Liao, Soochow University

- 40.1: **Invited Paper:** Marching Towards Theoretical Limits of Blue Fluorescent OLEDs with BI > 300
Xiao Liang, Jiangsu Sunera Technology, Wuxi, China
- 40.2: **Invited Paper:** Prolonging Device Lifetime of Blue Organic Light-Emitting Diodes
Sunghan Kim, Samsung Display Co., Ltd., Yongin, South Korea
- 40.3: **Distinguished Paper:** Realization of Ultra High Efficient Fluorescent Blue OLED
Satomi Tasaki, Idemitsu Kosan Co., Ltd., Chiba, Japan
- 40.4: **Double EML Structure for High Efficiency Organic Light Emitting Diode**
Eun-Hyung Lee, LG Display Co., Ltd., Seoul, South Korea

Session 41: Stretchable High-Resolution Displays (Conformable Wearable Displays)

Thursday, May 12, 2022 / 9:00 AM - 10:20 AM / Room LL20BC

Chair: Yong Taek Hong, Seoul National University

Co-Chair: Jeong-Ik Lee, ETRI

- 41.1: **Invited Paper:** The Technical Advances of Stretchable Display for High Pixel Density and High Stretchability
Jangyeol Yoon, Samsung Display, Yongin, South Korea
- 41.2: **Invited Paper:** Active-Matrix Micro-LED Stretchable Display and Technical Challenges
Haeyoon Jung, LG Display, Seoul, South Korea
- 41.3: **Invited Paper:** A High Resolution Stretchable Micro-LED Display
Cheng-Liang Wang, AU Optronics, Hsinchu, Taiwan Roc
- 41.4: **Invited Paper:** A 200 PPI Oval Shape Stretchable AMOLED Display
Pinfan Wang, BOE Technology Group Co., Ltd., Beijing, China

Session 42: Light Field Displays (Hyper-Realistic Displays (AR/VR/MR) / Display Systems)

Thursday, May 12, 2022 / 10:40 AM - 12:00 PM / Room 220B

Chair: Brian Schowengerdt, University of Washington

Co-Chair: Shinichi Uehara, AGC Inc.

- 42.1: **Invited Paper:** High-Resolution Light-Field AR at Comparable Computing Cost to Stereo 3D
Tomas Sluka, CREAL, Ecublens, Switzerland
- 42.2: **Spatial Resolution-Tripled Integral Imaging Light Field Displays with No Loss of Angular Resolution by Recombining Subpixels with Zero Sampling Error**
Wenchao Yang, Sun Yat-Sen University, Guangzhou, China
- 42.3: **Real-time Rendering for Integral Imaging Light Field Displays Based on a Voxel-Pixel Lookup Table**
Quanzhen Wan, Sun Yat-Sen University, Guangzhou, China
- 42.4: **Near-Eye Light Field Displays with Computational Vision Correction by Manipulating Vector Sampling Rays**
Yuqing Qiu, Sun Yat-Sen University, Guangzhou, China

Session 43: Micro-LEDs II (Emissive, Micro-LED, and Quantum-Dot Displays)

Thursday, May 12, 2022 / 10:40 AM - 11:40 AM / Room 220C

Chair: Francois Templier, CEA-LETI

Co-Chair: Larry Weber, Consultant

- 43.1: **Invited Paper:** Recent Advancements in microLED Testing and Inspection
David Lewis, InZiv, Jerusalem, Israel
- 43.2: **Low Efficiency Attenuation and Stable Monochromaticity for Non-Polar m-Plane Micro-Light-Emitting-Diodes (Micro-LEDs)**
Yibo Liu, Hong Kong University of Science and Technology, Hong Kong, Hong Kong
- 43.3: **Enhanced External Quantum Efficiency in the Low-Current Region Using Three Terminal GaN-Based Blue Micro-Light-Emitting Diodes**
Woo Jin Baek, Korea Advanced Institute of Science and Technology, Daejeon, South Korea

Session 44: E-Paper Display Technologies and Applications (Outdoor Displays / Flexible Displays and e-Paper)

Thursday, May 12, 2022 / 10:40 AM - 11:40 AM / Room LL21CD

Chair: Norihisa Kobayashi, Chiba University, Department of Image and Materials Science

Co-Chair: Shin Tson Wu, University Of Central Florida

- 44.1: **Distinguished Paper:** Electrophoretic Display Comprising Black, White, Red and Yellow Particles
HongMei Zang, E Ink California, LLC., Fremont, CA US
- 44.2: **Electronic Tile for Decoration of Outdoor/Indoor Walls**
Makoto Omodani, Tokyo Denki University, Saitama, Japan
- 44.3: **High-Performance Color MIP LCD with New Electrode Structure**
Takashi Sato, Sharp Display Technology Corporation, Nara, Japan

Session 45: OLED Devices II (OLEDs)

Thursday, May 12, 2022 / 10:40 AM - 12:00 PM / Room LL21EF

Chair: Nicholas Thompson, Universal Display Corporation

Co-Chair: Ji Ho Baek, LG Display

- 45.1: **Invited Paper:** Charge Balance in OLEDs: Optimization of Hole Injection Layer
Huiqing Pang, Beijing Summer Sprout Technology Co., Ltd., Beijing, China
- 45.2: **Invited Paper:** Towards High-Performance Organic Transistors for Display and other Applications

Karl Leo, Technische Universität, Dresden, Germany

45.3: **Effects of Near-UV Irradiation on Organic Light-emitting Diodes and Their Solutions Using UV Blocking Layer**

Jungjin Yang, Samsung Display, Giheung, South Korea

45.4: **A High Performance Full-fluorescent Electroluminescence solution with a 96.5% Coverage of B.T. 2020 Color Gamut**

Xiaojin Zhang, BOE Technology Group. Co., Ltd., Beijing, China

Session 46: Wearable and Skin-Like Displays (Conformable Wearable Displays / Flexible Displays and e-Paper / Active Matrix Devices)

Thursday, May 12, 2022 / 10:40 AM - 12:00 PM / Room LL20BC

Chair: Xiaojun Guo, Shanghai Jiao Tong University

Co-Chair: Yong Taek Hong, Seoul National University

46.1: **High-Performance Fiber-Based Red OLEDs and TFTs for Truly Wearable Textile Displays**

Kyung Cheol Choi, Korea Advanced Institute of Science and Technology (KAIST), Daejeon, South Korea

46.2: **Invited Paper: Strip-Helix-Fiber Architecture for Stretchable TFTs and Circuits**

Arokia Nathan, University of Cambridge, Cambridge, United Kingdom

46.3: **Invited Paper: Skin-like Organic Optoelectronic System for Real-time Heart Rate Monitoring**

Youngjun Yun, Samsung Electronics, Suwon, South Korea

46.4: **Reconfigurable and Reusable Soft Modular LED Blocks Assembly**

Yongtaek Hong, Seoul National University, Seoul, South Korea

Session 47: Automotive Display Optimizations (Automotive/Vehicular Displays and HMI Technologies)

Thursday, May 12, 2022 / 10:40 AM - 12:00 PM / Room LL20A

Chair: David Hermann, Volvo Car Corporation AB

Co-Chair: Eric Margulies, Universal Display Corporation

47.1: **Display Outdoor Visibility Enhancement Using Adaptive Tone Mapping**

Seungwan Kim, Samsung Electronics, Hwaseong, South Korea

47.2: **Monocular Depth Perception Enhancement Based on Joint Shading/Contrast Model and Motion Parallax (JSM)**

Seungchul Ryu, Faurecia Irystec Inc., Montreal, PQ Canada

47.3: **Electromagnetic Compatibility Problem Analysis of Flexible Vehicle Organic-Light Emitting Display**

Hang Dong, Chengdu BOE Optoelectronics Technology Co., Ltd., Chengdu, China

47.4: **Color Acceptability Threshold for Mixed Display Technology Automotive Cockpit**

Pooshpanjan Roy Biswas, Renault, Guyancourt, France

Session 48: LTPO Technology (Display Manufacturing / Active Matrix Devices)

Thursday, May 12, 2022 / 10:40 AM - 12:00 PM / Room LL20D

Chair: Dr. Chiwoo Kim, APS Holdings

Co-Chair: Jae-Hoon Lee, Samsung Display Co

48.1: **Solid-State Laser Crystallization for Poly-Si TFTs and Their Applications**

Hiroshi Tanabe, Tianma Japan, Ltd., Kawasaki, Japan

48.2: **Invited Paper: Advanced LTPO Technology for CMOS Driving**

KookChul Moon, Gachon University, Seongnam, South Korea

48.3: **Invited Paper: Fiber-Laser Processing of Si and IGZO Films for Advanced AMOLED Displays on Gen 8 Substrates**

James Im, Columbia University, New York, NY US

48.4: **LTPO Technology Development for Enhanced Display Performance: Image Sticking Phenomena, Circuit Operation and Backplane Process Integration**

D.-Y. Cho, Samsung Display, Yongin, South Korea

Session 49: Light Manipulation for VR/AR Optics (Hyper-Realistic Displays (AR/VR/MR) / Display Systems)

Thursday, May 12, 2022 / 1:30 PM - 3:10 PM / Room 220B

Chair: Nikhil Balram, Mojo Vision Inc.

Co-Chair: Jean-Pierre Guillou, Apple, Inc.

49.1: **Distinguished Paper: Gaze Matched Pupil Steering Maxwellian-View Augmented Reality Display**

Junyu Zou, University of Central Florida, Orlando, FL US

49.2: **Holographic Near-Eye Display with Expanded Eyebow Based on Exit Pupil Scanning**

Xinxing Xia, Shanghai University, Shanghai, China

49.3: **Building a Predictive Model of Contrast Ratio of Folded Optic Lens Systems for Virtual Reality**

Bing Hao, 3M Company, St. Paul, MN US

49.4: **Thin and Lightweight Head-Mounted Displays with Polarized Laser Backlights and Holographic Optics**

Shinichi Komura, Japan Display Inc., Mobarra, Japan

49.5: **Fast-response Pancharatnam-Berry Phase LC lens for AR Display**

Shuxin Liu, Shanghai Jiao Tong university, Shanghai, China

Session 50: Micro-LED Displays I (Emissive, Micro-LED, and Quantum-Dot Displays)

Thursday, May 12, 2022 / 1:30 PM - 2:50 PM / Room 220C

Chair: Dr. Khaled Ahmed, Intel Corporation

Co-Chair: Ioannis Kymissis, Columbia University

50.1: **Invited Paper: Designs and Manufacturing Processes for MicroLED Displays in Handsets, Smartwatches, and Personal Computers.**

Matthew Meitl, X Display Company, Inc., Research Triangle Park, NC US

50.2: **Invited Paper: Why Does the Road to High Volume Production of Micro-LED Displays Pass Through the Semiconductors Industry?**

Makarem Hussein, LuxNour Technologies, Hillsboro, OR US

50.3: **Status of MicroLED Mass Transfer Processes and Equipment**

Eric Virey, Yole Developpement, Portland, OR US

- 50.4: **Invited Paper: Development of MicroLED Display Technology and Applications**
Ying-Tsang Liu, PlayNitride Display Co., Ltd., Miaoli, Taiwan Roc

Session 51: Large and Tiled Display Technologies (Outdoor Displays / Display Systems)

Thursday, May 12, 2022 / 1:30 PM - 2:50 PM / Room LL21CD

Chair: K Kälantär, Global Optical Solutions

Co-Chair: Shin Tson Wu, University Of Central Florida

- 51.1: **Method to Suppress Tiled Display Seam Visibility**
Shenping Li, Corning Research & Development Corporation, Corning, NY US
- 51.2: **Glass Solution for Zero Border Design (ZBD) TVs: Its Advantages and Prevention of Border Light Leakage**
Tomohiro Ishikawa, Corning Incorporated, Corning, NY US
- 51.3: **65-inch Splicing Screen Adapted to a Wide Temperature Range and High Brightness**
Peng Xi Wang, Hefei BOE Display Technology Co., Ltd., Hefei, China
- 51.4: **Design, Measurements and Evaluation of Exterior Displays for Autonomous Cars**
Karlheinz Blankenbach, Pforzheim University Display Lab, Pforzheim, Germany

Session 52: OLED Displays I (OLEDs)

Thursday, May 12, 2022 / 1:30 PM - 3:10 PM / Room LL21EF

Chair: Yifan Zhang, Apple, Inc.

Co-Chair: Sangmoo Choi, Google LLC

- 52.1: **Invited Paper: Technical Progress of OLED Displays for Premium TVs**
Hong Jae Shin, LG Display, Paju, South Korea
- 52.2: **Ultrawide-Color Gamut, Low-Power Consumption White OLEDs for Large-Sized 8K OLED TV**
Juanjuan You, Hefei BOE Joint Technology Co., Ltd., Hefei, China
- 52.3: **Enhanced Viewing Angle Performance of an Advanced WRGB OLED Technology**
Don Gyou Lee, LG Display, Seoul, South Korea
- 52.4: **Novel POL-less OLED Structure with High Optical Gain**
Jongbeom Hong, Samsung Display, Yongin, South Korea
- 52.5: **A Color Gamut Mapping Method Using an OLED Display Model**
Deoksoo Park, Samsung Display, Hwaseong, South Korea

Session 53: Foldable Displays (Flexible Displays and e-Paper)

Thursday, May 12, 2022 / 1:30 PM - 2:30 PM / Room LL20BC

Chair: Dr. Joon Young Yang, LG Display Co. Ltd

Co-Chair: Shiming Shi, BOE

- 53.1: **The Foldable Display Architecture Technique Depending on Wide Temperature Range and Folding Curvature**
Min-Ho Lee, LG Display, Seoul, South Korea
- 53.2: **Analysis on the Advantages of Water-Drop Shape Foldable Display**
Shi Shi, BOE Technology Group Co., Ltd., Beijing, China
- 53.3: **Worldwide First Real Borderless and High Resolution Micro-LED Display**
Tin Kang, AU Optronics Corp., Hsinchu, Taiwan Roc

Session 54: HUD and Transparent Automotive Displays (Automotive/Vehicular Displays and HMI Technologies)

Thursday, May 12, 2022 / 1:30 PM - 3:10 PM / Room LL20A

Chair: David Hermann, Volvo Car Corporation AB

Co-Chair: Haruhiko Okumura, Toshiba Corporation

- 54.1: **Invited Paper: AR in an Automobile: 3D AR HUD**
Jae Won Cha, Naver Labs, Seongnam, South Korea
- 54.2: **A Measurement-Based Image Compositing for 3D Head-Up-Display**
Akinori Sato, Kyocera Corporation, Yasu, Japan
- 54.3: **Reduced Solar-Loading Using Micro-Mirror Array in Automotive HUD**
Kenneth Li, Optonomus Technologies Inc., Agoura Hills, CA US
- 54.4: **Distinguished Paper: Low-Diffraction Transparent μ LED Displays with Optimized Pixel Structure**
Qian Yang, University of Central Florida, Orlando, FL US
- 54.5: **Consideration of Image Distance on Cognitive Tunneling with Augmented Reality Head Up Displays**
Joe Pullukat, NS North America/Nippon Seiki, Troy, MI US

Session 55: Advanced Manufacturing Process Technologies (Display Manufacturing)

Thursday, May 12, 2022 / 1:30 PM - 2:50 PM / Room LL20D

Chair: Joerg Winkler, PLANSEE SE

Co-Chair: Tian Xiao, NEXT Biometrics Inc.

- 55.1: **Deposition of Conductive and Insulating Materials at Micrometer Scale for Display-Component Prototyping**
Piotr Kowalczewski, XTPL SA, Wroc?aw, Poland
- 55.2: **Roll-to-Plate Nanoimprint Lithography as Etching Mask Creating Large Area Structured Surfaces**
Jan Matthijs ter Meulen, Morphotonics B.V., Veldhoven, Netherlands
- 55.3: **Development Low Temperature Metal Dry Etching Equipment via ECR Plasma Source**
Chiwoo Kim, APS Research Corporation, Cheonan, South Korea
- 55.4: **True Printing Process for Integration of Optoelectronic MicroDevices into Functionalized Surfaces**
Reza Chaji, VueReal Inc., Waterloo, ON Canada

Session 56: System Architectures for VR/AR/MR (*Hyper-Realistic Displays (AR/VR/MR) / Display Systems*)

Thursday, May 12, 2022 / 3:10 PM - 4:10 PM / Room 220B

Chair: *W. Hendrick, Collins Aerospace*

Co-Chair: *Brian Berkeley, Highlight Display, LLC*

- 56.1: **Novel Optical Structure of OLED Panel for Immersive and Seamless VR**
Kwangsoo Bae, Samsung Display, Yongin, South Korea
- 56.2: **A Distraction-Free Display System Using Embedded Asynchronous Time Warp**
Wook Hong, RAONTECH Inc., Seongnam, South Korea
- 56.3: **New Ultra Low-Power High Brightness Microdisplays Enabling Broad Applications**
Philipp Wartenberg, Fraunhofer Institute for Organic Electronics, Dresden, Germany

Session 57: Micro-LED Displays II (*Emissive, Micro-LED, and Quantum-Dot Displays*)

Thursday, May 12, 2022 / 3:10 PM - 4:30 PM / Room 220C

Chair: *Ioannis Kymissis, Columbia University*

Co-Chair: *Jonathan Steckel, ST Microelectronics*

- 57.1: **ActiveHogel Light-Field Display: An Application of Next Generation μ LED Pixels**
Thomas Burnett, FoV3D, Austin, TX US
- 57.2: **Invited Paper: Self-Aligned Colored MicroLED Microdisplay for Compact AR Applications**
Reza Chaji, VueReal Inc., Waterloo, ON Canada
- 57.3: **MircoLED Display Integration on 300mm Advanced CMOS Platform**
Soeren Steudel, MICLEDI Microdisplays BV, Leuven, Belgium
- 57.4: **Invited Paper: Progress on Key Innovations in Direct-View μ LED Display Manufacturing**
Mingwei Zhu, Applied Materials, Inc., Santa Clara, CA US

Session 58: Smart Windows (*Outdoor Displays / Liquid Crystal Technology / Emerging Technologies and Applications*)

Thursday, May 12, 2022 / 3:10 PM - 4:30 PM / Room LL21CD

Chair: *Abhishek Srivastava, Hong Kong University of Science & Technology*

Co-Chair: *Karlheinz Blankenbach, Pforzheim University*

- 58.1: **Invited Paper: LC Dynamic Glazing – The Window Becomes a Pixel and the Façade a Giant Display**
Michael Grund, Merck KGaA, Darmstadt, HI Germany
- 58.2: **ELM: A Revolutionary New Smart Glass Technology**
Romarc Massard, Elstar Dynamics, Eindhoven, Netherlands
- 58.3: **Switchable Liquid Crystal Phase Grating with Rainbow-Free Hazy States**
Chin An Lin, AU Optronics Corporation, Hsinchu, Taiwan Roc
- 58.4: **Factors Affecting the Thermal Performance of Dye-Doped Liquid Crystal Smart Window**
Zhan Li, Beijing BOE Sensor Technology Co., Ltd., Beijing, China

Session 59: OLED Displays II (*OLEDs*)

Thursday, May 12, 2022 / 3:10 PM - 4:30 PM / Room LL21EF

Chair: *DZ Peng, Tianma*

Co-Chair: *Yuan-Chun Wu, China Star Optoelectronics*

- 59.1: **Invited Paper: Scaling Down of OLED Pixels Enabled by Photolithography**
Jan Genoe, imec, Leuven, Belgium
- 59.2: **Invited Paper: High Color Gamut Organic Light-emitting Diode Microdisplay for Augmented Reality/Virtual Reality Devices**
Chan-mo Kang, Electronics and Telecommunications Research Institute, Daejeon, South Korea
- 59.3: **A Thin, Transparent Encapsulation Film with Excellent Gap-filling Performance for Ultra-High-Resolution OLEDs via Vapor-Phase Deposited Polymeric Layer**
Byeong Gyu Roh, LG Display, Paju, South Korea
- 59.4: **Premium Black for Large sized White OLED**
Garam Hong, LG Display, Paju, South Korea

Session 60: E-Paper Technologies (*Flexible Displays and e-Paper*)

Thursday, May 12, 2022 / 3:10 PM - 4:10 PM / Room LL20BC

Chair: *Makoto Omodani, Tokyo Denki University*

Co-Chair: *HongMai Zang, E Ink California*

- 60.1: **Distinguished Paper: An Electrophoretic E-Paper Device with Stretchable, Washable, and Rewritable Functions**
Boru Yang, Sun Yat-Sen University, Guangzhou, China
- 60.2: **Image Plane Separation Artefacts in Multi-layer Color Reflective Displays**
Alex Henzen, South China Normal University, Guangzhou, China
- 60.3: **Invited Paper: Active-Matrix Digital Microfluidics System for Single Cells Manipulation**
Hanbin Ma, Guangdong ACXEL Micro & Nano Tech Co., Ltd., Foshan, China

Session 61: Novel Large-Area Automotive Displays (*Automotive/Vehicular Displays and HMI Technologies*)

Thursday, May 12, 2022 / 3:10 PM - 4:30 PM / Room LL20A

Chair: *Casey Kang, Corning Incorporated*

Co-Chair: *Eric Margulies, Universal Display Corporation*

- 61.1: **Invited Paper: OLED Technology for Automotive Display Applications**
Tomasz Tarnowski, Mercedes - Benz AG, Sindelfingen, Germany
- 61.2: **Invited Paper: ShyTech Displays High Resolution Displays Hidden Behind Decorative Surfaces**
Juergen Baethis, Continental Automotive GmbH, Babenhausen, Germany
- 61.3: **Research on Switchable Privacy Mode Applied to Automotive Displays**

Zhi Zhang, BOE Optoelectronics Technology Co., Ltd., Beijing, China

- 61.4: **Display Visual Security: From Laptop Privacy to No Driver Distraction for Automotive Passenger Infotainment**
Graham Woodgate, Rain Technology Research Ltd., Oxford, United Kingdom

Session 62: Innovative Glass Substrates and Processing (Display Manufacturing)

Thursday, May 12, 2022 / 3:10 PM - 4:30 PM / Room LL20D

Chair: Dr. Andriy Romanyuk, Glas Troesch AG

Co-Chair: Kazutaka Hayashi, AGC Inc.

- 62.1: **Large Area Ion Implantation Source for Production of Anti-Reflection Surfaces in Glass and Sapphire Substrates**
Alexander Welsh, Malachite Technologies, Inc., San Francisco, CA US
- 62.2: **Ultra-Flat, Low-Density, and High-Refractive-Index Glass Wafers for Augmented Reality: Weight Reduction as Key Enabler for Consumer Devices**
Frederik Bachhuber, SCHOTT AG, Mainz, Germany
- 62.3: **Distinguished Paper: High Precise Laser Glass Cutting for Future Display**
Woohyun Jung, Samsung Display, Yongin, South Korea
- 62.4: **Investigation of the Influence of Film Stress on Glass Strength**
Wencheng Hu, HeFei BOE Photoelectric Technology Co., Ltd., Hefei, China

Session 63: Emerging Approaches for AR/VR/MR (Hyper-Realistic Displays (AR/VR/MR) / Emerging Technologies and Applications)

Friday, May 13, 2022 / 9:00 AM - 10:20 AM / Room 220B

Chair: Ian Underwood, University of Edinburgh

Co-Chair: Soon-Gi Park, LetinAR

- 63.1: **Distinguished Paper: Microsecond High-Contrast Continuous 2.25pi Phase Modulation Based on Non-linear Kerr Effect of VADHFLC**
Zhengnan Yuan, Hong Kong University of Science and Technology, Hong Kong, Hong Kong
- 63.2: **Research on Stray Light Affecting the Imaging of Fresnel Lens in Virtual Reality Equipment**
Haitao Huang, BOE Technology Group Co., Ltd., Beijing, China
- 63.3: **High-Directivity Emitting Pixel Devices for Advanced Display Applications**
Chung-Chih Wu, National Taiwan University, Taipei, Taiwan Roc
- 63.4: **A Novel Real-Time Full-Color 3D Holographic (Diffraction) Video Capture, Processing And Transmission Pipeline Using Off-the-Shelf Hardware**
Ankur Samanta, University of Toronto, Toronto, ON Canada

Session 64: Mini-LED BLU for HDR Display (Display Systems)

Friday, May 13, 2022 / 9:00 AM - 10:40 AM / Room 220C

Chair: K Kälantär, Global Optical Solutions

Co-Chair: Daming Xu, Apple Inc

- 64.1: **A Local Dimming Technology of Scene Adaptation for Massive Mini-LED**
Ran Duan, BOE Technology Group Co., Ltd., Beijing, China
- 64.2: **Ultra-Thin RGB-Mini-LED Direct Back Light for High-end Professional Liquid Crystal Displays**
Xianqin Meng, BOE Technology Group Co., Ltd., Beijing, China
- 64.3: **Patterned Glass Diffuser for Mini-LED Count Reduction**
Xiang-Dong Mi, Corning Incorporated, Corning, NY US
- 64.4: **Mini-LED Driving Circuit with Power Saving Mechanism for Use in LCD Backlight Module**
Chih-Lung Lin, National Cheng Kung University, Tainan, Taiwan Roc
- 64.5: **Glass Circuit Board for Mini-LED Backlight of LCD**
Young-suk Lee, CTCK (Corning Technology Center Korea), Asan, South Korea

Session 65: Machine Learning for Image Enhancement (Machine Learning for Displays / Display Electronics / Applied Vision)

Friday, May 13, 2022 / 9:00 AM - 10:40 AM / Room LL21CD

Chair: Chaohao Wang, Apple Inc.

Co-Chair: Mainak Biswas, Google

- 65.1: **Deep Learning-Enabled Image Content Adaptive Driving Algorithm for Field Sequential Color LCDs with Mini-LED Backlight**
Qin Zong, Sun Yat-Sen University, Guangzhou, China
- 65.2: **A Light and Fast Branched Neural Network using Perceptual Optimization for High-Quality Visual Restoration of UDC images**
Jaihyun Koh, Samsung Display, Yongin, South Korea
- 65.3: **Invited Paper: Deep Learning-Based Image Enhancement for HDR Imaging**
Suk-Ju Kang, Sogang University, Seoul, South Korea
- 65.4: **Foveated Super Resolution Network for Virtual Reality Head Mounted Displays**
Hyoungsik Nam, Kyung Hee University, Seoul, South Korea
- 65.5: **AI based Simulation and Design Space Exploration for Pixel Layout**
Keuk Jin Jeong, Samsung Display Co., Ltd., Yongin, South Korea

Session 66: OLED Materials I (OLEDs)

Friday, May 13, 2022 / 9:00 AM - 10:20 AM / Room LL21EF

Chair: Chihaya Adachi, Kyushu University

Co-Chair: Changwoong Chu, Samsung Display Company

- 66.1: **Invited Paper: Hole Transport Materials – Key Enablers Future OLED Display Evolution**
Jens Engelhart, Merck KGaA, Darmstadt, Germany
- 66.2: **Invited Paper: Delayed Fluorescence from Energetically Inverted Singlet and Triplet Excited States for Efficient Organic Light-Emitting Diodes**
Naoya Aizawa, Osaka University, Suita, Japan
- 66.3: **Active Learning for the Design of Novel OLED Materials**
Hadi Abroshan, Schrödinger Inc., Portland, OR US

- 66.4: **Understanding the Electron Injection/Transport Mechanism in OLEDs by Using a Superbase as Electron Injection Layer**
Tsubasa Sasaki, NHK Science & Technology Research Laboratories, Tokyo, Japan

Session 67: Flexible Displays (Flexible Displays and e-Paper)

Friday, May 13, 2022 / 9:00 AM - 10:20 AM / Room LL20BC

Chair: *Arokia Nathan, Darwin College, University of Cambridge*

Co-Chair: *Winston Wang, AU Optronics Corp*

- 67.1: **Comparison of In-Folding and Out-Folding Stress on Electrical Performance of Poly-Si TFTs on Polyimide Substrate for Foldable AMOLED Display**
Mohammad Billah, Kyung Hee University, Seoul, South Korea
- 67.2: **Invited Paper: Organic Thin-Film Transistor Flexible Hybrid Integration for Low-Power Ubiquitous Sensor Systems**
Xiaojun Guo, Shanghai Jiao Tong University, Shanghai, China
- 67.3: **Predicting The Impact Resistance of Flexible Display Panels based on Mo Thin Film Residual Stress**
Jung Hwa Park, Samsung Display Co., Ltd., Yongin, AL South Korea
- 67.4: **Research on Design and Lamination of 180° Curly CG**
Yang Yang, BOE OLED R&D Center, Chengdu, China

Session 68: Displays and Visual Performance (Applied Vision)

Friday, May 13, 2022 / 9:00 AM - 10:20 AM / Room LL20A

Chair: *Jennifer Gille, Consultant*

Co-Chair: *Youngshin Kwak, Ulsan National Institute of Science and Technology*

- 68.1: **Evaluation for Reaction Time of Gaming Displays**
Yan Jin, LG Display, Seoul, South Korea
- 68.2: **Considering the Effects of Display Persistence on Eye Movements and Readability in Virtual Reality**
T. Scott Murdison, Reality Labs at Meta, Redmond, WA US
- 68.3: **Importance of Individual Adaptation in Visually-Fidelitous Dynamic-Range Compression from HDR to SDR Images**
Saki Iwaida, Kagoshima Clinical Engineering College, Kagoshima, Japan
- 68.4: **A Text Legibility Improvement Method for OLED Devices**
Hyunkyung Song, Samsung Display Co., Ltd, Yongin, South Korea

Session 69: Materials and Processes for Flexible Displays (Display Manufacturing)

Friday, May 13, 2022 / 9:00 AM - 10:20 AM / Room LL20D

Chair: *Dr Robert Visser, Applied Materials*

Co-Chair: *Toshiaki Arai, JOLED Inc*

- 69.1: **Inkjet-Printable Optically Clear Silicone Resin for Display Fabrication**
Juyoung Yook, Dow Chemical Silicones Korea Co., Ltd, Jincheon, South Korea
- 69.2: **A Universal Method for the Lamination of Arbitrary Stretchable Substrate Pairs without Compromising the Elastic Properties of the Substrates**
Sung Gap Im, KAIST, Daejeon, South Korea
- 69.3: **Invited Paper: Opportunities for High Performance Display Manufacturing Enabled by OTFTs Using an 80 Degrees Celsius Maximum Process Temperature**
Simon Ogier, SmartKem, Sedgefield, United Kingdom
- 69.4: **Collimating and Recycling Linear Evaporation Source for AMOLED Mass Production**
Sungmoon Kim, DepoLab, Paju, South Korea

Session 70: Light-Field and Foveated Imaging for AR/VR/MR (Hyper-Realistic Displays (AR/VR/MR) / Emerging Technologies and Applications / Liquid Crystal Technology)

Friday, May 13, 2022 / 10:40 AM - 12:00 PM / Room 220B

Chair: *Gary Jones, Nanoquantum Corporation*

Co-Chair: *Akihiro Mochizuki, I-CORE Technology, LLC*

- 70.1: **Distinguished Paper: Foveated Imaging by Polarization Multiplexing for Compact Near-Eye Displays**
Kun Yin, University of Central Florida, Orlando, FL US
- 70.2: **A Design for Near Eye Light Field Display**
Jian Gao, BOE, Beijing, China
- 70.3: **Invited Paper: High Resolution Light Field VR LCD**
Yung-Hsun Wu, Innolux Corp., Miaoli County, Taiwan Roc
- 70.4: **Invited Paper: Light Field Displays for Reverse Passthrough VR**
Nathan Matsuda, Reality Labs Research, Meta, Redmond, WA US

Session 71: Projection Light Sources (Display Systems)

Friday, May 13, 2022 / 10:40 AM - 12:00 PM / Room 220C

Chair: *David Eccles*

Co-Chair: *Hidekazu Hatanaka, Ushio Inc.*

- 71.1: **Invited Paper: GaN-Based Watt-Class High-Power Edge-Emitting Lasers and Milliwatt-Class Vertical-Cavity Surface-Emitting Lasers**
Takuya Ozaki, Nichia Corporation, Anan, Japan
- 71.2: **Invited Paper: High Power Red Laser Diodes for Display Applications**
Satoshi Kawanaka, USHIO Inc., Shizuoka, Japan
- 71.3: **Static Laser Phosphor for Projectors with Rotating Tilted Mirror**
Kenneth Li, Optonomus Technologies Inc., Agoura Hills, CA US
- 71.4: **Laser Phosphor Light Source using Compound Reflectors for Projection Display**
Kenneth Li, Optonomus Technologies Inc., Agoura Hills, CA US

Session 72: Machine Learning for Failure and Artifact Detection (*Machine Learning for Displays / Display Manufacturing / Display Measurement*)

Friday, May 13, 2022 / 10:40 AM - 12:00 PM / Room LL21CD

Chair: Prof. Hyungsik Nam, Kyung Hee University

Co-Chair: Dr. Robert Visser, Applied Materials

- 72.1: **In-Line Mura Detection Using Convolutional Neural Network in Display Manufacturing**
Satoru Tomita, Japan Display Inc., Chiba, Japan
- 72.2: **A Proposal for Image Compression Algorithm For Display Test Images**
Gang Xu, Jingce Electronics USA, San Jose, CA US
- 72.3: **Deep Learning Based Visual Defect Detection in Noisy and Imbalanced Data**
Qisen Cheng, Samsung Display America Lab, San Jose, CA US
- 72.4: **Invited Paper: Synthetic Defect Generation for Display Front-of-Screen Quality Inspection: A Survey**
Meng Cao, Apple, Cupertino, CA US

Session 73: OLED Materials II (*OLEDs*)

Friday, May 13, 2022 / 10:40 AM - 12:00 PM / Room LL21EF

Chair: Jang Hyuk Kwon, Kyung Hee University

Co-Chair: Hitoshi Kuma, Idemitsu Kosan Co., Ltd.

- 73.1: **Invited Paper: Decoration Strategy in Para Boron Position: An Effective Way to Achieve Ideal Multi-Resonance Emitters**
Lian Duan, Tsinghua University, Peking, China
- 73.2: **Invited Paper: High Efficiency Organic Light-Emitting Diodes Based on Purely Organic Emitters**
Shi-Jian Su, South China University of Technology, Guangzhou, China
- 73.3: **Achieving Deep Blue Color in Diboron Embedded Multi-Resonance Thermally Activated Delayed Fluorescence Emitter for Narrowband OLEDs**
Kenkera Naveen, Kyung Hee University, Seoul, South Korea
- 73.4: **Novel Materials and Structures for High Efficiency and Long Lifetime Green Phosphorescent OLEDs in Automotive Applications**
Soojung Youn, Samsung Display, Yongin, South Korea

Session 74: Flexible Displays and Materials (*Flexible Displays and e-Paper*)

Friday, May 13, 2022 / 10:40 AM - 12:00 PM / Room LL20BC

Chair: Kyung Cheol Choi, KAIST

Co-Chair: Simon Kang, Apple

- 74.1: **31" Flexible Printed OLED TV Display Technology: It's TV Mobile**
Jueng Gil (James) Lee, Guangdong Juhua Printed Display Technology Co. Ltd., Guangzhou, China
- 74.2: **Invited Paper: Highly Reliable Dielectric interlayers for Flexible Displays and e-Paper**
Atsuko Yamamoto, Merck Electronics Ltd., Shizuoka, Japan
- 74.3: **Invited Paper: Getting Thinner and Thinner with a New Flexible platform - Challenges and Solutions for Flexible Displays**
Dong-Mee Song, The Electronics Business of Merck KGaA, Darmstadt, Germany
- 74.4: **Development of Flexible Full-Color Mini-LED Display Using Simultaneous Transfer and Bonding (SITRAB) Technology**
Jiho Joo, Electronics and Telecommunications Research Institute, Daejeon, South Korea

Session 75: HDR and Color (*Applied Vision*)

Friday, May 13, 2022 / 10:40 AM - 12:00 PM / Room LL20A

Chair: Sakuichi Ohtsuka, International College of Technology

Co-Chair: David Hoffman, Google

- 75.1: **Brightness and Vividness of High Dynamic Range Displayed Imagery**
Luke Hellwig, Munsell Color Science Laboratory, Rochester, NY US
- 75.2: **Effect of Chromatic Aberration Correction on Visually Lossless Compression**
Sanjida Sharmin Mohona, York University, Toronto, ON Canada
- 75.3: **Field Sequential Color Displays with Simultaneously Suppressed Color Breakup and Flicker Based on Multi-Objective Optimization**
Qin Zong, Sun Yat-Sen University, Guangzhou, China
- 75.4: **Low Luminance JND and JNCD**
Sunyoung Park, Samsung Display, Yongin, South Korea

Session 76: Narrow Border Technologies (*Display Manufacturing*)

Friday, May 13, 2022 / 10:40 AM - 12:00 PM / Room LL20D

Chair: Greg Gibson, nTact

Co-Chair: Winston Wang, AU Optronics Corp

- 76.1: **Invited Paper: MicroLED Display with Tiling Technology**
Wen-Lung Chen, AU Optronics Corporation, Hsinchu, Taiwan Roc
- 76.2: **Development of Custom Shaped OLED Display**
Zhongyuan Wu, Hefei BOE Joint Technology Co., Ltd., Hefei, China
- 76.3: **Invited Paper: Slim Mini LED Backlight for HDR Compatible Mobile Displays**
Hisashi Watanabe, Sharp Display Technology Corporation, Tenri, Japan
- 76.4: **Invited Paper: Innovation Solutions That Lead to AMLED Technologies**
Minghua Xuan, Beijing BOE Display Technology Co., Ltd., Beijing, China

Poster Session

Thursday, May 12, 2022 / 5:00 PM - 8:00 PM / Room 220A

Active-Matrix Devices

- P.1: Uni-Color Column Line Pentile-Type Pixel Arrangement Design for Low Driving Power Consumption AMOLED Displays**
Sangmo0 Choi, Google LLC, Mountain View, CA US
- P.2: Nitrogen Behaviors in PEALD-grown SiO₂ Films Using N₂O Plasma Reactant and Its Application in ALD-IZO TFTs**
Jin-Seong Park, Hanyang University, Seongdong, South Korea
- P.3: High Temperature Annealing Behavior of IGZO Using Plasma Enhanced Atomic Layer Deposition**
Jin-Seong Park, Hanyang University, Seongdong, South Korea
- P.4: A New Evaluation System for Metal Oxide Compound Semiconductor Film**
KookChul Moon, Gachon University, Seongnam, South Korea
- P.5: A New PWM Driving Circuit with Threshold Voltage and I-R Rise Compensating Capability for Mini-LED Backlight**
Chih-Lung Lin, National Cheng Kung University, Tainan, Taiwan Roc
- P.6: 2731-ppi OLED Display with Low Power Consumption and Wide Viewing Angle Using OS/Si VLSI Process Technology**
Kiyotaka Kimura, Semiconductor Energy Laboratory Co., Ltd., Atsugi, Japan
- P.7: AMOLED Pixel Circuit for Strain Compensation in Stretchable Display**
Soo-Yeon Lee, Seoul National University, Seoul, South Korea
- P.8: Analysis on Degradation Mechanism of Oxide Semiconductor FETs with High Tolerance to Intense NBTIS**
Yukinori Shima, Semiconductor Energy Laboratory Co., Ltd., Tochigi, Japan
- P.9: Two-Mode PWM Driven Micro-LED Displays with Dual-Gate Metal-Oxide TFTs**
Jia Fu, Peking University, Shenzhen, China
- P.10: Emit Signals Reused Gate Driver Design for Ultra-Narrow-Bezel Micro-LED Display Based on Metal-Oxide TFTs**
Xin Zheng, Peking University, Shenzhen, China
- P.11: The Effects of Ar Dilution on N₂O/SiH₄ PECVD for the Growth of Silicon oxide Thin Films with Improved Breakdown Voltage Characteristics**
Aram Kim, LG Display, Paju, South Korea
- P.12: Exponential Dependence of Photocurrent on Reciprocal of Channel Length in Amorphous InZnO Thin-Film Transistors with Short Channel**
Jie Chen, Peking University Shenzhen Graduate School, Shenzhen, China
- P.13: Comprehensive Study of the TFTs Fabricated in the (100)-Oriented Grain-Boundary-Free Silicon Thin Film Obtained by Green CW-Laser Lateral Crystallization**
Nobuo Sasaki, Sasaki Consulting, Kanagawa, Japan
- P.14: Effects of Film Density on IGZO Based TFT Device Reliability**
Jaeyoon Park, LG Display, Paju, South Korea
- P.15: Charge Trap-Based Synaptic Transistor Employing In-Ga-Zn-O as Channel and Trap Layers for Bio-Inspired Neuromorphic Computing**
Junhyeong Park, Seoul National University, Seoul, South Korea
- P.16: A New a-IGZO TFT Pixel Circuit Compensating Threshold Voltage and Mobility for Active-Matrix OLED with Source Follower Method**
Ji-Hwan Park, Seoul National University, Seoul, South Korea
- P.17: Outstanding Image Sticking Performance via L-SWTF Channel Tuning in AMOLED Display Application**
Yinglong Huang, BOE Optoelectronics Technology Co., Ltd., Chengdu, China
- P.18: Low Voltage Oxide Transistor with High Dielectric Tantalum Oxide Gate Insulator by Thermal Oxidation of Tantalum**
Byung Seong Bae, Hoseo University, Asan, South Korea
- P.19: Performance Development of Oxide Semiconductor Photodiode with High Work Function Electrode Suitable for Mass Production**
Pengfei Gu, BOE Technology Group Co. Ltd, Beijing, China
- P.20: High Quality Self-Aligned Coplanar Thin-Film Transistors with SOG Materials for High Transparent AMOLED Display**
Wei Liu, BOE Technology Group Co., Ltd., BeiJing, China
- P.21: Indium-Gallium-Zinc Oxide Thin-Film Transistors for High-Resolution Active-Matrix Ferroelectric Liquid-Crystal Displays**
Sisi Wang, The Hong Kong University of Science and Technology, Kowloon, Hong Kong
- P.22: Effects of Self-Assembled Monolayer on Contact Resistance Between IGZO and Electrode for High-Resolution Display**
Yoonyoung Chung, POSTECH, Pohang, South Korea
- P.23: A Monolithically Integrated Artificial Compound Eye for Proximity Pattern Recognition**
Zhou Zhi Chao, Hong Kong University of Science and Technology, Hong Kong, Hong Kong
- P.24: *Distinguished Paper*: Gate Driver with LTPO TFT Circuits for Low Power Consumption and Narrow Bezel AMOLED Displays**
Jin Jang, Kyung Hee University, Seoul, South Korea
- P.25: Solution Processed CH₃NH₃PbI₃/ZnO Phototransistor with High Photodetectivity**
Farjana Haque, Kyung Hee University, Seoul, South Korea
- P.26: AMOLED Pixel Circuit Compensating for Stretching and I-R Drop**
Hyuck Su Lee, Hoseo University, Asan, South Korea
- P.27: A Novel PWM Driving Pixel Circuit with Metal-Oxide TFTs for Micro-LED Display**
Ko-Ruey Jen, AU Optronics, Hsinchu, Taiwan Roc
- P.28: Development of Low Resistivity Gate Metal Process for LTPS TFTs Array Backplane Applications**
Jia-Hong Ye, AU Optronics Corporation, Hsinchu, Taiwan Roc
- P.29: Influence of the Static Bending Stress on LTPS TFT**
Shuang Guo, Hefei Visionox Technology Co., Ltd., Hefei, China
- P.30: Thermally Activated and Field-Enhanced Diffusion of Dopants in a-InGaZnO TFTs Under Circuit Operations and its Correlation to the Device Stabilities**
Chang Il Ryoo, Kookmin University, Seoul, South Korea
- P.31: Low Temperature of 150c Processed IGTO Thin-Film Transistor for Flexible Display Application**
Jae Kyeong Jeong, Hanyang University, Seoul, South Korea
- P.32: Investigation on Mechanism of Illumination Mura in AMOLED Display with LTPS TFT Backplane After Long Term Localized Illumination**
Enqing Guo, Visionox Technology Inc, Hebei, China
- P.137: High Performance Coplanar a-IGZO TFT Image Sensor with Partial Passivation-Less Structure for Digital X-Ray Detector**
Jaeho Yoon, LG Display Co., Ltd., Paju, South Korea
- P.139: Process Simulation Reflecting Hydrogen/Oxygen for Oxide Semiconductor Thin Film Transistor**
Kihwan Kim, Samsung Display, Yongin, South Korea
- P.140: WITHDRAWN**
- P.141: Modulation of Subthreshold Current in In-Ga-Zn-O Thin-film Transistor for OLED Display using Electrohydrodynamic Jet Printing**
Hyun Jae Kim, Yonsei University, Seoul, South Korea

Applied Vision

- P.33: Measuring Color Strength for Wide Color Gamut OLEDs**
YungKyung Park, Ewha Womans University, Seoul, South Korea

Automotive/Vehicular Displays and HMI Technologies

- P.34: Automotive Local dimming Integrated System for LCD MDL**
Xiaoxia Wang, BOE Optoelectronics Technology Co., Ltd., Beijing, China
- P.35: The Study of Vehicle Bright Backlight with Local Dimming Effect**
Yuanyuan Zhu, BOE Optoelectronics Technology Co., Ltd., Beijing, China
- P.144: The Effect of the Reference Image on the Side Window of the Car of Motion Sickness**
Chien Ju Li, Industrial Technology Research Institute, Hsinchu, Taiwan Roc
- P.145: AR HUD System Realized By Holographic Display Technology**
Chien Yu Chen, National Taiwan University of Science And Technology, Taipei, Taiwan Roc

Display Electronics: Display Driving Technology

- P.36: WITHDRAWN**
- P.37: Adaptive Frequency Driving Scan Driver with NOR Logic Gate Based on a-InGaZnO TFTs**
Hojin Lee, Soongsil University, Seoul, South Korea
- P.38: Low-Power a-IGZO TFT Shift Register Featuring i-PUA Gate Dielectric**
Hojin Lee, Soongsil University, Seoul, South Korea
- P.39: The IR Drop Compensation Method of AMOLED Display for Dynamic Power Control**
Wei-Jhe Ma, Novatek Microelectronics Corp., Hsinchu, Taiwan Roc
- P.40: Techniques of Touch Sensing and Display Driving for Avoiding Display Artifacts for Flexible OLED Applications**
Daisuke Ito, Synaptics Japan G.K., Nakano, Japan
- P.41: A Combined PAM / PWM Driving Scheme for High Uniformity of Micro-LED Displays**
Julian Ritter, Saarland University, Saarbrücken, Germany
- P.42: A New Integrated Scan/Emission Driver Circuit with Progressive Emission Driving Method for Micro-LED Display**
Sung-Hyuck Ahn, Sungkyunkwan University, Suwon, South Korea
- P.43: Finely Programmable Pulse Width Shift Register for Luminance Control of AMOLED Displays**
Hyoongsik Nam, Kyung Hee University, Seoul, South Korea
- P.44: MPRT Enhancement Gate Driver Circuit Employing IGZO TFTs for Image-Quality Improvement**
Xuehuan Feng, Hefei BOE Joint Technology Co. Ltd., Hefei, China
- P.45: High Efficiency DC-DC Converter for IT OLED Displays**
Yoon-Young Lee, Samsung Display, Yongin, South Korea

Display Manufacturing

- P.46: New Type of Unbounded Screen Full-Attachment TV Set**
Wenbo Dong, Hefei BOE Display Technology Co., Ltd., Hefei, China
- P.47: A Repair Method for Improving Pad Damage of COG Mini-LED**
Hai Tang, BOE MLED Technology Co., Ltd., Beijing, China
- P.48: Analysis of Degree of Imidization of Polyimide Organic Film Through Retardation Measurement**
Nakcho Choi, Samsung Display Co., Ltd., Yongin, South Korea
- P.49: Physics-Based Simulator for Predictictiin of Organic Layer Profile Using Microfluidics**
Hyungkeon Cho, Samsung Display, Yongin, South Korea
- P.50: Inkjet Printing Design and Analysis for Thin and Uniform Organic Encapsulation Layer on OLEDs**
Heechang Yoon, Samsung Display Co., Ltd., Gyeonggi, South Korea
- P.51: Study on the Sealing Property of Narrow Border Display**
Zhenyu Zhang, Hefei Xinsheng Photoelectric Technology Co., Ltd., Hefei, China
- P.52: Novel Forming Technology of 3D Cover Glass with Induction Heating System for Curved-Corner Display**
Seungho Kim, Samsung Display Co., Ltd., Yongin, South Korea
- P.53: A Study on Conceptual Design in Foam Tape of Curved Display using Topology Optimization**
Min Gu Kim, Samsung Display Co., Ltd., Yongin, South Korea
- P.54: Development of Heat Free / Low Temperature Process High Refractive Index Materials for Display**
Kazuki Urakawa, Tokyo Ohka Kogyo Co., Ltd., Kanagawa, Japan
- P.55: Development of Photosensitive Material for Mini/Micro LED Display**
Yasunori Takahashi, Sumitomo Bakelite Co., Ltd., Fukuoka, Japan
- P.142: Cost of Operation Reduction and Performance Improvement of Crystallized a-Si Backplanes for OLED-Displays by Solid-State-Laser Annealing (SLA)**
Hans-Juergen Kahlert, INNOVAVENT GmbH, Goettingen, Germany

Display Measurement

- P.56: Simulation and Improvement of TCO Luminance Angular Uniformity Based on Techwiz and LightTools Software**
Hanyan Sun, Beijing BOE Display Technology Co., Ltd., Beijing, China
- P.57: Improved Modulation Transfer Function (MTF) for Aerial Image Formed with AIRR by Use of Two Transparent Spheres**
Kazuaki Takiyama, Utsunomiya University, Utsunomiya, Japan
- P.58: Measurement of AR Displays in Positioning Accuracy**
Xi Mou, Hangzhou Santest Technology Co., Ltd., Zhejiang, China
- P.59: In-Fab Raman Spectroscopy for Defect Analysis of Random Failures**
Yong-Woon Lim, Samsung Display, Yongin, South Korea

Display Systems: Emerging Display Technologies and Applications

- P.60: New Flexible & Lightweight RGB LED Video-Foil for Digital Signage**
Florian Kall, LightnTec GmbH, Karlsruhe, Germany
- P.61: Dual Cell Display System for Intelligent Viewing-Adjustable LCDs**
Yuxu Geng, Chongqing BOE Optoelectronics Technology Co., Ltd., Chongqing, China
- P.62: Adaptive Pixel-Based Local Color Uniformity Compensation for AMOLED Displays**
Wan-Nung Tsung, Novatek Microelectronics Corporation, Hsinchu, Taiwan Roc

Display Systems: Projection

- P.63: Design and Fabrication of Wide-Viewing-Angle Ambient Light Rejection Front Projection Screen**
Fung-Hsu Wu, BenQ Materials Corp., Taoyuan, Taiwan Roc

Display Systems: VR/AR/MR Technologies

- P.64: The Micro-LC Lens for 2D/3D Switchable Displays**
Weili Zhao, BOE Technology Group Co., Ltd., Beijing, China
- P.65: Autostereoscopic Display for Two Viewers Providing Images Specific to Each Viewpoint**
Hideki Kakeya, University of Tsukuba, Tsukuba, Japan
- P.66: Application of Ergonomics in VR HMD Exit Pupil Positioning Design**
Yuhong Liu, Beijing BOE Optoelectronics Technology Co., Ltd., Beijing, China
- P.67: Design and Analysis of Deflection Structure for Light Field Display**
Kai Siang Hsu, National Taiwan University, Taipei, Taiwan Roc
- P.68: A Miniaturized Polarization-Multiplexed Dual-Plane Head-Mounted Display System for Augmented Reality**
Zekun Yan, Shanghai Jiao Tong University, Shanghai, China
- P.69: Omnidirectional and Self Adaptive High Dimensional 3D Display**
Shiming Shang, BOE Technology Group Co., Ltd., Beijing, China

Emerging Technologies and Applications

- P.70: Force Variation During Tactile Exploration Provide Crucial Information in Virtual Tactile Experience**
Youru Chen, BOE Technology Group Company, Ltd., Beijing, China
- P.71: Methods for Adopting High Resolutions Mobile Displays in Alternative Applications, Products and Markets**
Grant Jennings, Gowin Semiconductor, Austin, TX US
- P.72: Highly Uniform Speckle Pattern Created Via an Elastomeric Stencil Mask for High-Precision Digital Image Correlation Analysis of Substrate Stretching Deformation**
Yongtaek Hong, Seoul National University, Seoul, South Korea

Emissive, Micro-LED, and Quantum-Dot Displays: Micro-LEDs

- P.73: MicroLED Pixel Circuit Based on Metal Oxide Thin-Film Transistor with Progressive Emission Method Using Pulse Width Modulation**
Eun Kyo Jung, Sungkyunkwan University, Suwon, South Korea
- P.74: High Efficiency μ LED Light Engine for AR/VR Displays**
En-Lin Hsiang, University of Central Florida, Orlando, FL US
- P.75: MicroLED Pixel Circuit Capable of Always on Display Mode Operation for Mobile and Wearable Displays**
Yong-Hoo Hong, Sungkyunkwan University, Suwon, South Korea
- P.76: Elimination of Nanorods by Tetramethylammonium Hydroxide for the Fabrication of AlGaN-based UV-C Micro-LED Array**
Feng Feng, Hong Kong University of Science and Technology, Hong Kong, Hong Kong
- P.77: Advanced Encapsulation Film for Micro-LED Display**
Shih-Chieh Teng, BenQ Materials Corporation, Taoyuan, Taiwan Roc
- P.78: Atomic-Scale Sidewall Passivation for MicroLED Devices**
Jouko Lång, Comptek Solutions, Turku, Finland
- P.79: WITHDRAWN**
- P.80: Design Heuristics for Low Operating Voltage xLEDs**
Khaled Ahmed, Intel Corporation, San Jose, CA US

Emissive, Micro-LED, and Quantum-Dot Displays Posters: QD Color Conversion

- P.81: Enhanced Color Conversion Efficiency of Quantum Dot Layer using Low Refractive Index Layer**
Da Bin Kim, Foundation Technology Laboratory, LG Display, Seoul, South Korea
- P.82: Prediction Methodology for the Optical Properties of QDs with Arbitrary 3D Shape**
Hyunguk Cho, Samsung Display, Youngin, South Korea
- P.83: Oxygen Ratios Effect on the Photoluminescence Property of Zinc Oxide Thin Film Phosphor**
Chaoyang Li, Kochi University of Technology, Kochi, Japan
- P.84: Selective Coating CdSe/ZnS Quantum Dots on Stretchable Substrate with Controlled Density by Inducing Ligand Exchange Reaction**
Yongtaek Hong, Seoul National University, Seoul, South Korea
- P.85: Nanorod Down-Converted LED with Long Term Stability for Display Backlight**
Chengbin Kang, The Hong Kong University of Science and Technology, Clear Water Bay, Hong Kong
- P.86: Ink-Jet Printed Stable Full-Color Perovskite and Quantum Rod Color Filter**
Yiyang Gao, The Hong Kong University of Science and Technology, Clear Water Bay, Hong Kong

Emissive, Micro-LED, and Quantum-Dot Displays Posters: QD-LEDs

- P.87: Localized Surface Plasmon Resonance-Enhanced ZnSeTe Blue Quantum Dot Light-emitting Diodes with AuAg Alloy Nanoparticles**
Heesun Yang, Hongik University, Seoul, South Korea
- P.88: Efficiency Improvement of Top-Emission Green Quantum Dot Light-Emitting Diode with Dielectric-Metal-Dielectric Cathode**
Jiun-Haw Lee, National Taiwan University, Taipei, Taiwan Roc
- P.89: High-Efficiency Red Quantum Dot Light-Emitting Diodes with Acrylate-Treated ZnMgO as an Electron Transport Layer**
Heesun Yang, Hongik University, Seoul, South Korea
- P.90: Boosting the Efficiency of Cd-Free Blue Quantum Dot Light-Emitting Diodes via Charge Transport Layer Optimization**
Maocheng Jiang, BOE Technology Group Co., Ltd., Beijing, China
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